



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

ent Application

Assistant Commissioner for Patents

Washington, D.C. 20231

Re: Inventor(s): Title:

Sean Michael Seutter, Seshadri Ganguli, Mei Chang, Michael X. Yang, Ming Xi Low-Resistivity Tungsten from High-Pressure Chemical Vapor Deposition

Using Metal-Organic Precursors

Transmitted herewith is the patent application identified above, including:

- X Specification, claims and abstract, totaling <u>25</u> pages.
- X Drawings totaling 6 pages, Formal X Informal.
- X Executed Declaration and Power of Attorney.
- X Assignment of the invention to **Applied Materials, Inc.**
- X Assignment Recordation Cover Sheet
 - Information Disclosure Statement, PTO Form 1449 and () References

Fee Items	Claims Filed	Included With Basic Fee	Extra Claims	Fee Rate	Total
Total Claims	- 24	- 20 =	- 4	X \$18	\$ 72
Independent Claims	- 3	- 3 =	- 0	X \$80	\$ 0
Basic Filing Fee \$710					\$710

- XX The Commissioner is hereby authorized to charge \$782 to Deposit Account No. 50-1074
- The Commissioner is hereby authorized to charge any additional fees which may be required, or credit any overpayment to Deposit Account No. 50-1074. A duplicate copy of this transmittal is enclosed.
- XX Please address all future correspondence to:

PATENT COUNSEL APPLIED MATERIALS, INC. Legal Affairs Department P.O.BOX 450A Santa Clara, CA. 95052

I hereby certify that this correspondence is being deposited with the United States Postal Service as express mail in an envelope addressed to Box Patent Application, Assistant Commissioner for Patents, Washington, D.C. 20231

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Signature Tice Hackary

Respectfully submitted,

Robert W. Mulcahy Registration No. 25,436